



HANDBOOK OF

Magnetism

AND ADVANCED MAGNETIC MATERIALS

3

Fundamentals and Theory

Micromagnetism

**Novel Techniques for
Characterizing and Preparing
Samples**

Novel Materials

Spintronics and Magnetoelectronics

Editors-in-Chief

HELMUT KRONMÜLLER

STUART PARKIN

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Foreword

Thanks to its fascinating properties in both macroscopic and atomic dimensions magnetism has attracted the attention of philosophers and scientists from ancient times to the present day. Greek philosophers such as Thales and Anaxagoras believed in the divine origin of magnets. Diogenes adopted a materialistic point of view and proposed a materials exchange between magnetite and iron, while the most advanced hypothesis was propagated by Empedokles, Epicurus, and Democritus, who explained the long-range interactions between magnets by an effluvia transporting a form of dynamic field.

It took two millennia until, in the Age of Enlightenment, the discoveries of Coulomb, Oersted, Faraday, and Maxwell gave for the first time a quantitative description of the long-range interactions between magnets on the basis of electromagnetic fields. It was the discovery of the magnetic properties of the electron by Niels Bohr, Uhlenbeck and Goudsmit, which finally gave an explanation of magnetic properties on the atomic scale. These findings may be considered as the starting point of modern research on fundamental magnetic properties and the development of high-quality magnetic materials. The conventional theory of magnetism is mainly based on Weiss's molecular field theory, whereas the modern theory of magnetism, pioneered by Heisenberg and Dirac, uses quantum-mechanical descriptions based on the properties of exchange interactions. It fell to, however, the scientists of the second half of the twentieth century to the present day, to arrive at a quantitative first-principles description of magnetically ordered spin systems and their excited states.

Since the first application of the famous oxide, magnetite, as a compass in ancient times in China, and from the early Middle Ages in Europe, magnetic materials have become an indispensable part of our daily life. In many ways, the modern world is an automated one, which uses ferro- and ferrimagnetic materials in all important technical fields. Magnetic materials are used in all dimensions from the nanoscale for nonvolatile high-density recording and sensor applications to the macroscale for high-voltage transformers, high-energy generators, and levitation mechanisms. This widespread use of magnetic materials has initiated increasing research in academia, national research laboratories, and

industry. Despite the fact that development in some areas of magnetic materials research is so rapid that publications can only present the current state of the art, the articles in this handbook present critical, fundamental information, which will guide and inform research efforts across the field.

The *Handbook of Magnetism and Advanced Magnetic Materials*, consisting of five volumes, presents in the form of review articles a broad range of contributions focusing on both fundamental properties and the development of spin-ordered materials with outstanding magnetic properties. The progress made during the last few decades in computational sciences and in advanced materials preparation techniques, has dramatically improved our knowledge of the fundamental properties, and increased our ability to produce materials with tailored properties in nanoscale dimensions. If one considers the most promising new research directions in modern solid-state physics and materials science it becomes clear that phenomena related to the individual electronic spin moment play an increasingly important role. Spintronics, the spin Hall effect, qubits, and spin-torque interactions are fascinating examples of such new research directions. All these new developments are very closely related to low-dimensional electron systems and the progress made in nanosciences, which are among the main topics of the present handbook.

Magnetic materials used so far have, in general, been optimized with respect to only *one* outstanding property, such as, for example, high permeability, high coercivity, or high remanence. For many modern applications, however, it is a prerequisite that a whole spectrum of properties be combined and optimized. Modern technologies in material science allow the realization of multifunctional materials not accessible only a few years ago. Examples of such developments are the combination of ferromagnetic and semiconducting properties with tunable Curie temperatures and high-permeability nanocrystalline alloys with low conductivity and Curie temperatures considerably above room temperature.

Our present knowledge of magnetism is reviewed in the five volumes of this handbook, with over 120 articles written by leading experts in the field, covering the fundamentals of electron theory of spin-ordered materials, the basics and applications of the continuum theory of micromagnetism, and the development of new measuring and

sample-preparation techniques. Furthermore numerous novel multifunctional materials such as intermetallic compounds, ferromagnetic semiconductors, Heusler alloys, half-metals, manganites, pnictides, and molecular magnets, as well as biomagnetic materials are discussed in detail in the handbook. Recent developments in magnetoelectronics and spintronics are also addressed in numerous articles. These two research fields are rapidly growing owing to their high potential for nonvolatile, high-density magnetic recording. The bases for these applications, as outlined in several articles, are the giant magnetoresistance effect, the spin-dependent tunneling effect, the method of spin-injection, and magnetization processes induced by spin-torque interactions.

This handbook summarizes our knowledge of modern magnetism gained during the last few decades, and as such

will be a helpful source of new ideas and future developments for physicists, chemists, material scientists, electrical engineers, and applied mathematicians. In particular the development of nanoscale systems including thin films and multilayered systems has led to new phenomena and novel applications which accelerate multidisciplinary cooperation between different groups of scientists. In addition, therefore, this handbook may also be considered as a bridge between basic scientific understanding and important technological developments.

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Preface to Volume 3

The *Handbook of Magnetism and Advanced Magnetic Materials* provides an up-to-date review of our present understanding of the fundamental properties of spin-ordered solids and their applications for high-quality magnetic devices. Since the first description of the industrial production of compass needles by the father of magnetism, William Gilbert, in his famous book *De Magnete*, magnetism has penetrated all important technical fields including electrical energy transport, high-power electromotors and generators, telecommunications, micromechanical automation, navigation, aviation and space operations, magnetocaloric refrigeration, nondestructive testing, computer sciences, high-density recording, biomagnetism, and medicine as well as numerous household applications. All these applications have become possible because of the dramatic increase in our knowledge and understanding of the fundamental properties of spin-ordered materials and the discovery of numerous novel materials. The discovery of new effects based on spin ordering has promoted the development of a multitude of new applications. Examples of this are the giant magnetoresistive effect, the spin-dependent tunneling effect, and the spin-torque effect. The development of novel electron theoretical methods for the treatment of spin-dependent multiparticle interactions now allows predictions on the electronic states of spin-ordered alloys, intermetallic compounds, and investigations of the effect of dimensionality. Parallel to the progress in theory, which is also based on the availability of increasing computational facilities, remarkable progress concerning novel magnetic materials has taken place during the last few decades. Whereas in the first half of the twentieth century, iron-carbon steels, iron-silicon alloys, permalloy, and alnico played the major role for hard and soft magnetic materials, the second half of the twentieth century and the beginning of the twenty-first century were characterized by the discovery and development of numerous materials with fascinating electronic and magnetic properties. Well-known examples for this are the intermetallic compounds of rare earth and transition metals, the amorphous alloys, heavy Fermion systems, half-metals, and the tremendous field of thin-film multilayers with their exciting properties of giant magnetoresistances and spin-dependent tunneling phenomena.

Since the middle of the twentieth century, the progress made in the field of magnetism may be attributed to the following developments:

1. Many-body electron theoretical calculations of spin-ordered ground states and their thermally and optically excited states including magnetic phase transitions, spin-dependent transport problems, and the interaction between magnetism and superconductivity.
2. Continuum theoretical micromagnetism of spin structures and the dynamics of magnetization processes on both nano- and micrometer scales.
3. The development of new measuring techniques: X-ray and neutron diffraction methods, X-ray magnetic circular dichroism, spin-polarized photoemission and spin-polarized electron spectroscopy, Lorentz microscopy, electron holography, and magneto-optical methods.
4. Advanced material preparation techniques ranging from the production of multilayers by molecular beam epitaxy and sputtering techniques to patterning and self-assembling techniques as well as the preparation of high-quality single crystals.
5. Discovery and development of novel ferro- and ferrimagnetic materials with extraordinary physical properties. Intermetallic compounds with coercivities from 1 to 5 T and amorphous and nanocrystalline alloys with permeabilities up to 10^6 . Diluted ferromagnetic semiconductors and half-metallic Heusler alloys play an increasing role in spintronics and magnetoelectronics. Heavy Fermion systems and magnetocaloric and magnetic shape memory alloys have become highly active research fields.
6. The development of magnetoelectronics and spintronics, which are the most rapidly growing research fields with attractive applications for high-density, nonvolatile magnetic recording systems. The phenomena of spin-torque effects, spin-dependent transport of carriers, and spin-dependent tunneling are the basis for future progress.

In the second half of the twentieth century our knowledge of magnetic materials increased enormously. Conventional ferromagnetic materials, such as iron-carbon steel, permalloy, Fe-Si, and alnico, as well as magnetically soft and hard

ferrites, which were the leading magnetic materials up to the 1960s, have to some extent been replaced by novel, more efficient, materials. Even though Fe–Si still retains its importance in the fields of transformers and electrical machines, there now exist amorphous and nanocrystalline alloys with giant permeabilities of 10^5 – 10^6 , which are used in many applications of soft magnetic cores, high-performance electrical machines, and the rapidly expanding field of magnetic sensors. A similar situation has developed in the field of hard magnetic materials, where the discovery of intermetallic compounds of rare earth and transition metals has led to supermagnets with coercive fields from 2 to 8 T and energy products up to 500 kJ m^{-3} . The magnitude of these properties exceeds what is observed in alnico by a factor of five.

This progress has been achieved largely by the development of new preparation techniques, for example, the use of rapid quenching methods with quenching rates of 10^6 K s^{-1} has allowed the preparation of amorphous and nanocrystalline magnetic alloys, and the liquid-phase sintering technique has enabled supermagnets to be produced. Thin-film preparation methods based on sputtering and molecular-beam epitaxy have made it possible to generate artificial systems of complex multilayered films. The microstructure and perfection of these layered systems have been continuously improved over recent decades, leading to systems with tailored and reproducible magnetic properties. Remarkable developments have also taken place in the formation of small magnetic clusters and thin wires, and the corresponding formation of self-ordered systems of small particles. In particular, the role of nanocrystalline particles in medicine and biology, and the techniques for their preparation, have become important research fields.

Owing to the rapidly developing fields of magnetoelectronics and spintronics, the demand for ferromagnetic semiconductors and materials with a high degree of polarization of the conduction electrons, such as Heusler alloys, has become very strong. Ferromagnetic oxides and diluted oxides alloyed with magnetic transition metals have, therefore, become an important class of materials. The combination of novel materials and novel, advanced preparation techniques has led to numerous discoveries of outstanding magnetic effects, such as the exchange bias effects which play a role in spin valves, and giant magnetoresistance film systems.

Parallel to the progress made in fundamental theories and the discovery of novel magnetic materials, novel measuring methods have been developed which allow a profound characterization of the magnetic properties. Furthermore the development of new preparation techniques, in particular, in nanoscale dimensions, has influenced the whole field of magnetism. The progress made in these fields is reviewed in this volume in eight parts.

The first two parts deal with the application of neutron and X-ray scattering for the study of spin structures, spin-wave excitations, and applications for determining domain states by neutron reflection and scattering. The use of polarized neutrons for the investigation of magnetic nanostructures such as superlattices, and systems applied in spintronics is described extensively. Synchrotron radiation techniques based on X-ray magnetic circular dichroism are shown to be effective methods of analyzing spin and orbital moments as well as dynamic magnetization processes in the subnanosecond range. The results obtained for the motion of vortices under applied fields are one of the outstanding results of these investigations.

The third part is devoted to photoemission microscopy applied for the study of dynamic magnetization processes in the picosecond and femtosecond regions. Dynamical effects such as domain nucleation, domain-wall movements, magnetization precession, and vortex-core rotations are demonstrated.

Electron microscopy and electron holography applied to magnetically ordered materials is reviewed in the fourth part. These methods have been successfully developed for the study of nanostructures, ultrathin films, and surface phenomena. These contributions discuss the experimental realization, the theoretical backgrounds, and application to the study of thin films and particles as a function of microstructural and magnetic parameters.

The fifth part deals with the application of magneto-optical techniques for the study of domains and dynamic magnetization processes. Here the investigation of domains by the magneto-optical Kerr effect, the magnetization-induced second-harmonic generation by laser light, and the investigation of spin waves and spin dynamics is described by selected experiments on typical magnetic materials. The magnetic behavior of itinerant ferromagnetic alloys excited by an instantaneous perturbation is investigated by the time-resolved Kerr effect. The different timescales responsible for the establishment of thermal equilibrium are analyzed.

The sixth part of this volume is related to spin-polarized electron spectroscopy and magnetic resonance. These highly advanced methods are applied for the study of ultrathin magnetic films, spin-polarized surface states, interface states, and quantum-well states. The technologically important oxide systems such as half-metallic transition metal oxides and ferromagnetic/oxide interfaces are investigated. The application of the spin-polarized electron energy-loss spectroscopy is shown to be a most effective method to study spin waves at magnetic surfaces. Exchange interactions are derived from surface spin-wave energy spectra for the first time.

The seventh part deals with nanomagnetism – applications and characterization. Here the method of scanning probe techniques is presented and outlined in detail for the magnetic

force microscopy and the spin-polarized scanning tunneling microscopy. Application of these techniques to numerous sample systems such as hard disks, nanoparticles, and epitaxial surfaces are presented. Three contributions deal with preparation techniques based on patterning techniques, chemical synthesis of nanoparticles, and the nanoimprint technology of patterned nanostructures. Here the current novel techniques such as ion-beam lithography, writing by scanning Ga focused beams, and film deposition on prepatterned templates are discussed. The progress made on monodisperse magnetic nanoparticles with regard to chemical synthesis is discussed in relation to actual magnetic systems.

The eighth part of this volume reviews the important field of material growth techniques. The method of molecular beam epitaxy as well as the growth of single crystals by a variety of methods is described in detail. These techniques are shown to be the basis for further development in the field of spintronics and the precise determination of magnetic material properties. Epitaxial Heusler alloys on III–V semiconductors, rare-earth and transition-metal multilayers, and superlattices are in the focus of these contributions. Special emphasis is placed on molecular beam epitaxy as a growth method that allows *in situ* control of the growth and structure of the material.

This handbook has been compiled with the collaboration of an international advisory board whose distinguished members have invested their time to present a broad and deep spectrum of the most important activities in the field of magnetism, at the beginning of the twenty-first century. The

continuous advice and support of the advisory board is highly appreciated. Their active motivation of the authors is one of the reasons for the successful completion of this handbook. Their patience and help in organizing the submission of articles of the highest standard are to be acknowledged. Without doubt too the publication of this handbook is the result of the active cooperation of all the authors. Their contributions should be considered as a solid foundation for further developments in the field of magnetism.

During the preparation of this handbook the cooperation of the editors with the staff of the Chichester offices of John Wiley & Sons over several years has been extremely effective and is appreciated. Questions concerning authors, and the layout of the handbook were discussed intensely to guarantee optimum solutions. Since the first meetings with David Hughes, Publishing Editor, a friendly and productive atmosphere has prevailed which helped in the completion of the handbook. The editors also acknowledge the cooperation of the Publishing Assistants and Project Editor who managed the continuous flow of information between the Chichester offices and the editors.

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Abbreviations and Acronyms

0D	Zero-dimensional	AMS	Anisotropic Magnetostriction
1D	One-dimensional	ANNH	Axial Next-nearest-neighbor
2D	Two-dimensional		Heisenberg Model
2DBZ	Two-dimensional Brillouin Zone	ANNI	Anisotropic Next-nearest-neighbor
2DEG	Two-dimensional Electron Gas		Ising Model
2DES	Two-dimensional Electron Systems	AP	Antiparallel
2DHG	Two-dimensional Hole Gases	APW	Augmented Plane Wave
2PPE	Two-photon Photoemission	AR	Andreev Reflection
3D	Three-dimensional	AR	Aspect Ratio
5-FU	5-Fluorouracil	ARAES	Angular Resolved Auger Electron Spectroscopies
		ARM	Advanced Recording Model
a-MCMB	Activated Mesocarbon Microbead	ARPES	Angle-resolved Photoemission Spectroscopy
AA	Asymptotic Analysis		Angle-resolved Ultraviolet Photoemission Spectroscopy
AAF	Artificial Antiferromagnetic	ARUPS	Atomic Sphere Approximation
AB	Aharonov–Bohm		Atomic Units
ABS	Air Bearing Surface	ASA	Akulov–Zener–Callen
ABS	Air-lock Braking Systems	au	
AC	Alternating Current	AZC	
ACP	Air Cushion Press		
AD/DA	Analog-to-Digital/Digital-to-Analog		
AF or AFM	Antiferromagnetic	BA	Born Approximation
AFC	Antiferromagnetically Coupled	BAP	Bir–Aronov–Pikus
AFI	Antiferromagnetic Insulator	BARC	Bead Array Counter
AFM	Atomic Force Microscope/Microscopy	BC	Boundary Condition
AFQ	Antiferroquadrupolar	bcc	Body Centered Cubic
AGFM	Alternating Gradient Force Magnetometer	BD-BZS	Band Degeneration and Brillouin Zone Symmetry
AGG	Abnormal Grain Growth	BDF	Backward Difference
AGM	Alternating Gradient Magnetometer	BEC	Bose–Einstein Condensation
AHE	Anomalous Hall Effect	BEEL	Ballistic Electron Emission Luminescence
AI	Ab Initio		
AII	Anisotropic Interion Interactions	BEEM	Ballistic Electron Emission Microscopy
AL	Atomic Layers	BEM	Boundary Element Method
ALPS	Applications and Libraries For Physics Simulations	BEMM	Ballistic Electron Magnetic Microscopy
ALS	Advanced Light Source	BEP	Beam Equivalent Pressure
AM	Amplitude Modulation	BETS	Bis(ethylenedithio)tetraselenafulvalene
AM	Angular Momenta	BFK	Brooks–Fletcher–Katayama
AMMs	Anisotropic Molecular Magnets	BGAs	Bulk Glassy Alloys
AMR	Anisotropic Magnetoresistance	BGRIMM	Beijing General Research Institute of Metallurgy Mining
AMR	Anisotropic Magnetoresistive		

BHEM	Ballistic Hole Emission Microscopy	CNR	Contrast-To-Noise Ratio
BHMM	Ballistic Hole Magnetic Microscopy	CNT	Classical Nucleation Theory
BIA	Bulk Inversion Asymmetry	COI	Charge Ordered Insulating
BIG	Bismuth-substituted Iron Garnet	COO	Charge/orbital Ordered
BIS	Bremsstrahlung Isochromat Spectroscopy	CP	Cross Polarization
BLS	Brillouin Light Scattering	CPA	Coherent Potential Approximation
BM	Band Models	CPGE	Circular Photogalvanic Effect
BMR	Ballistic Magnetoresistance	CPM	Classical Preisach Model
BPW	Bethe–Peierls–Weiss	CPP	Current Perpendicular To Plane
BSE	Back Scattered Electron	CPP-GMR	Current Perpendicular To Plane Giant Magnetoresistance
BSS	Blankenbecler Scalapino Sugar	CT	Charge Transfer
BVMSW	Backward Volume Magnetostatic Spin-Wave	CTEM	Conventional Transmission Electron Microscopy
BZ	Brillouin Zone	CTF	Contrast Transfer Function
CA	Canted Antiferromagnet	CVD	Chemical Vapor Deposition
CAICISS	Coaxial Impact Collision Ion Scattering Technique	CW	Continuous Wave
CB	Coulomb Blockade	CZ	Czochralski
CC	Coupled Cluster	DA	Disaccommodation
CCD	Charge-coupled Device	dc	Direct Current
ccp	Cubic Close-packed	DCA	Dynamical Cluster Approximation
CCSD	Coupled Cluster Expansion With Singles And Doubles	DCD	Direct Current Demagnetization
CCT	Continuous Cooling Transformation	DE	Damon and Eshbach
CD	Compact Disc	DE	Differential Equations
CE	Conduction Band Electron	DE	Double-Exchange
CEF	Crystal Electric Field	DF	Density-functional
CEF	Crystalline Electric Field	DFA	Density-functional Approximation
CESR	Conduction Electron Spin Resonance	DFH	Digital Ferromagnetic Heterostructure
CF	Correlation Function	DFT	Density-functional Theory
CFCs	Chlorofluorocarbons	DHO	Damped Harmonic Oscillator
CFT	Conformal Field Theory	dHvA	De Haas–Van Alphen
CFTR	Cystic Fibrosis Conductance Regulator	DL	Double Layer
CGO	Conventional Grain-oriented	DL	Double Lorentzian
CI	Configuration Interaction	DLD	Delay Line Detector
CIMS	Current-induced Magnetization Switching	DM	Dzyaloshinsky–Moriya or Dzyaloshinskii–Moriya
CIP	Cold Isostatic Pressing	DMFA	Dynamic Mean Field Approximation
CIP	Current Flowing in the Plane	DMFT	Dynamical Mean Field Theory
CIP	Current-In-Plane	DMR	Density Magnetic Recording
CISP	Current-induced Spin Polarization	DMRG	Density Matrix Renormalization Group
CJT	Cooperative Jahn–Teller	DMSs	Diluted Magnetic Semiconductors
CLIO	Cross-linked Iron Oxides	DNP	Dynamic Nuclear Spin Polarization
CLM	Constrained Local Moment	DOF	Degrees of Freedom
CMD	Colossal Magnetodielectric	DOS	Density of States
CMOS	Complementary Metal Oxide Semiconductor	DP	D’Yakonov–Perel’
CMP	Chemical–Mechanical Polishing	DPC	Differential Phase Contrast
CMR	Colossal Magnetoresistance	DS	Domain State
		DSC	Differential Scanning Calorimetry
		DTA	Differential Thermal Analysis
		DTPA	Diethylenetriaminepentaacetic Acid
		DW	Domain Wall

DWBA	Distorted Wave Born Approximation	FEA	Finite Element Analysis
DWE	Direct Wiedemann Effect	FEG	Field Emission Gun
DWMR	Domain Wall Magnetoresistance	FEL	Free-Electron Laser
DWR	Domain Wall Resistance	FEM	Finite Element Method
DWs	Domain Walls	FET	Field Effect Transistor
EA	Edwards–Anderson	FF	Fourier Filtering
EB	Electric Bicycle	FFLO	Fulde–Ferrell–Larkin–Ovchinnikov
EB	Electron Beam	FFT	Fast Fourier Transform
EB	Exchange Bias	FI	Ferrimagnetic
EBL	Electron Beam Lithography	FI	Ferromagnetic Insulating/Insulator
EC	Elastic Constant	FIB	Focused Ion Beam
ECF	Extracellular Fluid	FIF	Ferromagnet-insulator-ferromagnet
ECV	Electrochemical Capacitance–Voltage	FIS	Ferromagnet-insulator-superconductor
ED	Easy Direction	FL	Fermi Liquid
EDCs	Energy Distribution Curves	FLAPW	Full Potential Linearized Augmented Plane-Wave
EDS	Energy Dispersive Spectroscopy	FLEX	Fluctuation Exchange
EDSR	Electric-Dipole Spin Resonance	FM	Ferromagnetic
EDX	Energy Dispersive X-ray	FM	Frequency Modulation
EELS	Electron Energy Loss Spectroscopy	FMM	Fast Multipole Method
EFA	Envelope Function Approximation	FMM	Ferromagnetic Metallic
EFAN	Electrical Force-assisted Nil	FMR	Ferromagnetic Resonance
EL	Electroluminescence	FMS	Forced Magnetostriction
EL	Electron-Lattice	FMSA	Ferromagnetic Shape Memory Alloy
EM	Elastic Moduli	FMSs	Ferromagnetic Semiconductors
EM	Electromagnetic	FO	Ferro-orbital
EMDs	Easy Magnetization Directions	FOM	Figure Of Merit
EMR	Extraordinary Magnetoresistance	FP	Fokker–Planck
EMTO	Exact Muffin-Tin Orbital	FPE	Fokker–Planck Equation
EOM	Equation Of Motion	FS	Fermi Surface
EPMA	Electron Probe-Microanalysis	FS	Ferromagnetic Semiconductor
EPR	Electron Paramagnetic Resonance	FSMAs	Ferromagnetic Shape Memory Alloys
EPS	Electronic Phase Separation	FSSS	Fisher Sub Sieve Seizer
ESP	Equal Spin Pairing	FT	Force Theorem
ESR	Electron Spin Resonance	FT	Fourier Transform
ETMs	Early Transition Metals	fu	Formula Unit
EV	Electric Vehicle	FV	Fluctuating Valence
EW	Elastic Wave	FVMSW	Forward-Volume Magnetostatic Spin-Wave
EX-MS	Exchange Magnetostriction	FWHM	Full Width at Half Maximum
EXAFS	Extended X-ray Absorption Fine Structure	FZ	Floating Zone
EY	Elliott–Yafet		
F	Ferromagnetic	g-TMR	g-Tensor Modulation Resonance
FC	Field Cooling/Cooled	GB	Grain Boundaries
fcc	Face Centered Cubic	GDCs	Giant Dielectric Constants
FCT	Face Centered Tetragonal	GE	General Electric
FD	Finite Difference	GFA	Glass-forming Ability
FDA	U.S. Federal Drug Administration	GGA	Generalized Gradient Approximation
FDT	Fluctuation-Dissipation Theorem	GGG	Ga–Gd–garnet
FE	Ferroelectric	GIND	Grazing Incidence Neutron Bragg Diffraction
FE	Field Emission		

GISANS	Grazing Incidence Small-Angle Scattering of Magnetic In-Plane Structures	IBMP	Ion Bombardment Induced Magnetic Patterning
GK	Goodenough–Kanamori	ICF	Interconfigurational
GMCE	Giant Magnetocaloric Effect	IEC	Interlayer Exchange Coupling
GMI	Giant Magnetoimpedance	IETS	Inelastic Electron Tunneling Spectroscopy
GMR	Giant Magnetoresistance	IF	Interface
GMR	Giant Magnetoresistive	IHD	Intermediate to High Damping
GS	Ground-state	IL	Interference Lithography
		ILD	Isotropic Long-range Dipolar
HAADF	High-angle Annular Dark-field	IMEC	Interuniversitair Micro-Elektronica Centrum
HAADF-STEM	High-angle Annular Dark-field Scanning Transmission Electron Microscopy	IMERs	Immobilized Magnetic Enzyme Reactors
HAMR	Heat Assisted Magnetic Recording	IMFP	Inelastic Mean Free Path
HAs	Heusler Alloys	IMS	Immunomagnetic Separation
HAST	Highly Accelerated Stress Test	INESC–MN	Institute of Engineering of Systems and Computers – Microsystems and Nanotechnologies
HB	Hubbard Band		
HCC	Hepatocellular Carcinoma	INS	Inelastic Neutron Scattering
hCG	Human Chorionic Gonadotropin	IPM	Interior Permanent Magnet
HDDR	Hydrogenation-Disproportionation-Desorption-Recombination	IPT	Iterated Perturbation Theory
HDDs	Hard Disk Drives	IR	Irreducible Representation
HDs	Hard Disks	IRM	Isothermal Remanent Magnetization
HEV	Hybrid Electric Vehicle	IRM	Isothermal Remanent Moment
HF	Hard Ferrite	IS	Irreducible Strain
HF	Hartree–Fock	ISR	Isotropic Short-Range
HF	Heavy Fermion	IWE	Inverse Wiedemann Effect
HF-EPR	High-Frequency Electron Paramagnetic Resonance		
HFCs	Heavy-Fermion Compounds	JASTEC	Japan Superconductor Technology
HFCs	Hydrofluorocarbons	JT	Jahn–Teller
HGMS	High-Gradient Magnetic Separator		
HGO	High Permeability, Grain-Oriented	K	Kondo
HH	Heavy-Hole	KKR	Korringa–Kohn–Rostoker
HM	Half Metallic	KKR-CPA	Korringa–Kohn–Rostoker-Coherent Potential Approximation
HM	Hubbard Model		
HMFs	Half Metallic Ferromagnets	KLM	Kondo Lattice Model
HMM	Half Metallic Materials	KR	Kerr Rotation
HMMs	Hard Magnetic Materials	KTO	Kubic Tensor Operator
HMs	Hard Magnetic Materials		
HREM	High-resolution Electron Microscopy	LA	Local Ansatz
HRIR	High-reflectance Infrared Mirror	LAFS	Law of Approach to Ferromagnetic Saturation
HRTEM	High-resolution Transmission Electron Microscopy	LAO	LaAlO ₃
HRXRD	High-resolution X-ray Diffraction	LBMO	La _{0.7} Ba _{0.3} MnO ₃
HS	High Symmetry	LCCSD	Linearized Coupled-Cluster Expansion with Singles and Doubles
HS	Hubbard–Stratonovich	LDA	Local Density Approximation
HTI	High-temperature Incommensurate	LDOS	Local Density Of States
HV	High Vacuum	LED	Light-emitting Diode
HWHM	Half-Width at Half-Maximum	LEED	Low Energy Electron Diffraction

LFL	Landau–Fermi Liquid	MEXAFS	Magnetic Extended Absorption Fine Structures
LGW	Landau–Ginzburg–Wilson	MExFM	Magnetic Exchange Force Microscopy
LH	Left-hand	MF	Mean Field
LH	Light-Hole	MFA	Mean Field Approximation
LHMs	Left-handed Materials	MFA	Mean Field-like Approach
LKKR	Layer Korringa–Kohn–Rostoker	MFM	Magnetic Force Microscope/ Microscopy
LL	Landau–Lifschitz	MI	Metal–Insulator
LL	Layer-by-Layer	micro-SQUIDs	micro-Superconducting Quantum Inter- ference Devices
LLG	Landau–Lifschitz–Gilbert	MIM	Metal–Insulator–Metal
LLs	Landau Levels	MIP	Mean Inner Potential
LMO	LaMnO ₃	MIS-FET	Metal–Insulator–Semiconductor Field- Effect Transistor
LMTO	Linear Muffin-Tin Orbital	MIT	Metal–Insulator Transition
LO	Longitudinal Optical	ML	Monolayer
LP	Lifshitz Point	ML	Multilayer
LPD	Laser Pulse Deposition	MLB	Magnetic Linear Birefringence
LSCMO	La _{0.7} (Ca _{0.5} Sr _{0.5})MnO ₃	MLCs	Multiplicative Logarithmic Corrections
LSDA	Local Spin Density Approximation	MLD	Magnetic Linear Dichroism
LSTP	Low Standby Power	MMEE	Magnetic Multielectron Excitations
LT	Low-temperature	MMICs	Monolithic Microwave Integrated Circuits
LT-MBE	Low-temperature Molecular-beam Epitaxy	MO	Magneto-optical
LTI	Low-temperature Incommensurate	MOCVD	Metalorganic Chemical Vapor Deposition
LTMs	Late Transition Metals	MOKE	Magneto-optical Kerr Effect
LTM–Met	Late Transition Metal–Metalloid	MOS	Metal Oxide Semiconductor
LTT	Low-temperature Tetragonal	MOSFET	Metal Oxide Semiconductor Field- Effect Transistor
L–G	Landau–Ginzburg	MPCs	Magnetic Photonic Crystals
MA	Magnetoacoustic	MPH	Magnetic Particle Hyperthermia
MAD	Metalorganic Aerosol Deposition	MPI	Magnetic Particle Imaging
MAE	Magnetic Anisotropy Energy	MPs	Magnetic Particles
MAE	Magnetoacoustic Emission	MR	Magnetoresistance
MAE	Magnetocrystalline Anisotropy Energy	MR	Magnetoresistive
MBE	Molecular Beam Epitaxy	MR	Matrix–Recursion
MC	Magnetoconductance	MRAM	Magnetic Random Access Memory
MC	Magnetocurrent	MRAM	Magnetoresistive Random Access Memory
MC	Monte Carlo	MRFM	Magnetic Resonance Force Microscopy
MCA	Magnetocrystalline Anisotropy	MRI	Magnetic Resonance Imaging
MCB	Magnetic Circular Birefringence	MRM	Magnetic Racetrack Memory
MCD	Magnetic Circular Dichroism	MS	Magnetostriction
MCE	Magnetocaloric Effect	MSBVM	Magnetostatic Backward Volume Mode
MCL	Magnetic Correlation Length	MSFVM	Magnetostatic Forward Volume Mode
MCP	Microchannel Plate	MSG	Magnetic Symmetry Group
MCRG	Monte Carlo Renormalization Group	MSH	Metal–Semiconductor Hybrids
MCS	Monte Carlo Step	MSHG	Magnetization-induced Second Harmonic Generation
MD	Multidomain		
MDCs	Momentum Distribution Curves		
ME	Magnetoelastic		
MEE	Migration-enhanced Epitaxy		
MEL	Magnetoelastic		
MEMS	Microelectromechanical Systems		
MES	Magnetic Equation of State		